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U.S. UTILITY Patent Application

PATENT NUMBER and
ISSUE DATE

APPL NUM 10040646	FILING DATE 01/07/2002	CLASS 216	SUBCLASS 24	GAU 1746	EXAMINER Alan Ko
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****APPLICANTS:** Nishiki Hirohiko; Atkinson James; Nakata Yukihiko;

****CONTINUING DATA VERIFIED:**

**** FOREIGN APPLICATIONS VERIFIED:**

PG-PUB	DO NOT PUBLISH <input type="checkbox"/>	RESCIND <input type="checkbox"/>
Foreign priority claimed <input type="checkbox"/> yes <input type="checkbox"/> no		ATTORNEY DOCKET NO
35 USC 119 conditions met <input type="checkbox"/> yes <input type="checkbox"/> no		SLA 0452
Verified and Acknowledged Examiners's initials		
TITLE : System and method for etching resin with an ozone wet etching process		

U S DEPT OF COMM /PAT & TM-PTO-436L/Rev. 12-94

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
ISSUE FEE Amount Due Date Paid		Total Claims	Print Claim for O.G.
		DRAWING Sheets Drwg. Figs.Drwg. Print Fig.	
<input type="checkbox"/> TERMINAL DISCLAIMER		Application Examiner	
		PREPARED FOR ISSUE	
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